Supporting Information for

Perylenothiophene Diimides: Physicochemical Properties and Applications in Organic Semiconducting Devices

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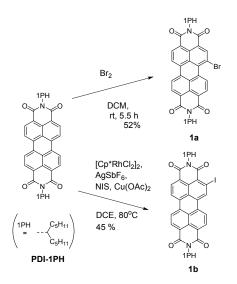
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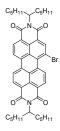
1. Synthesis of mono-halogenated PDIs

N,N'-Bis(1-penthylhexyl)-1-bromoperylene-3,4,9,10-tetracarboxydiimide (**1a**)¹ and N,N'-bis(1-pentylhexyl)-2-iodoperylene-3,4,9,10-tetracarboxydiimide (**1b**)² were synthesized from N,N'-bis(1-penthylhexyl)-perylene-3,4,9,10-tetracarboxydiimide³ according to the reported procedures.



Scheme S1. Synthesis of 1a and 1b.

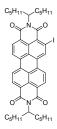
N,*N*'-Bis(1-penthylhexyl)-1-bromoperylene-3,4,9,10-tetracarboxydiimide (1a)



A mixture of *N*,*N*'-bis(1-penthylhexyl)-perylene-3,4,9,10-tetracarboxydiimide (3.86 g, 5.52 mmol) and bromine (33.7 g, 212 mmol) in 108 mL of dichloromethane was stirred at rt for 2 days. The mixture was quenched with diluted NaHSO₃ aqueous solution (30 mL) and extracted with dichloromethane (100 mL). Then, the solvent was evaporated and the residue was purified by column chromatography on silica gel eluted with dichloromethane/hexane (1:1, v/v) to give **1a** as an orange

solid (4.60 g, 52%): ¹H NMR (400 MHz, CDCl₃): δ 9.79 (d, *J* = 8.0 Hz, 1H), 8.91 (s, 1H), 8.69–8.67 (m, 3H), 8.59–8.57 (m, 2H), 5.22–5.12 (m, 2H), 2.31–2.21 (m, 4H), 1.94–1.85 (m, 4H), 1.43–1.21 (m, 24H), 0.84 (t, *J* = 6.8 Hz, 6H), 0.83 (t, *J* = 6.8 Hz, 12H); ¹³C NMR (100 MHz, CDCl₃): 163.9, 163.8, 163.1, 162.8, 139.2, 134.0, 133.7, 133.6, 131.1, 130.61, 130.55, 129.1, 128.9, 128.3, 128.2, 128.1, 127.2, 124.1, 124.0, 123.7, 123.3, 122.9, 122.6, 121.0, 55.1, 54.9, 32.5, 32.4, 31.74, 31.72, 26.63, 26.61, 22.5, 13.9; IR (KBr) v = 1701, 1661 cm⁻¹ (C=O); MP: 198.2–198.7 °C; HRMS (APCI) m/z calcd for C₄₆H₅₃BrN₂O₄: [M]⁺ 777.3267. Found: 777.3263.

N,*N*'-Bis(1-pentylhexyl)-2-iodoperylene-3,4,9,10-tetracarboxydiimide (1b)



A mixture of $[Cp*RhCl_2]_2$ (152 mg, 0.248 mmol) and AgSbF₆ (564 mg, 1.63 mmol) in dichloroethane (19 mL) was stirred at room temperature for 20 minutes. Then, *N*,*N*'-bis(1-penthylhexyl)-perylene-3,4,9,10-tetracarboxydiimide (3.30 g, 4.72 mmol), *N*-iodosuccinimide (1.385, 5.65 mmol), Cu(OAc)₂ (426 mg, 2.34 mmol), and dichloroethane (122 mL) was added and the mixture was stirred at 80 °C for 1 day. After cooling, the solvent was evaporated and the residue was purified by column chromatography on silica gel eluted with dichloromethane/hexane (1:3, v/v) to give **1b** as a red solid (1.75 g, 45%): ¹H NMR (400 MHz, CDCl₃): δ 9.12 (s, 1H), 8.69–8.64 (m, 3H), 8.57 (d, *J* = 8.0 Hz, 1H), 8.56 (d, *J* = 8.0 Hz, 1H), 8.52 (d, *J* = 8.0 Hz, 1H), 5.23–5.15 (m, 2H), 2.34–2.19 (m, 4H), 1.69– 1.83 (m, 4H), 1.44–1.23 (m, 24H), 0.86 (t, J = 6.8 Hz, 6H), 0.85 (t, J = 6.8 Hz, 6H); ¹³C NMR (100 MHz, CDCl₃): 163.94, 163.86, 162.9, 162.1, 138.2, 137.9, 134.8, 134.2, 133.8, 133.0, 131.8, 131.6, 131.4, 130.9, 129.5, 126.42, 126.35, 124.3, 124.1, 124.0, 123.8, 123.4, 123.2, 123.0, 101.2, 55.6, 55.0, 32.5, 32.4, 31.8, 26.7, 22.5, 13.9; IR (KBr) v = 1699, 1659 cm⁻¹ (C=O); MP: 207.2–208.2 °C; HRMS (APCI) m/z calcd for C₄₆H₅₃IN₂O₄: [M]⁺ 825.3128 Found: 825.3130.

2. Fabrication methods of organic devices

Fabrication and characteristics of OFET devices

dPTIa-, dPTIb-, IDT-PTIa-, and IDT-PTIb-based OFET devices were fabricated in a topcontact/bottom-gate (TCBG) configuration on a heavily doped n^+ -Si (100) wafer with a 200 nm thermally grown SiO₂ (capacitance: $C_i = 17.3$ nF cm⁻²). The substrate was treated with octadecyltrichlorosilane (ODTS) as reported previously.⁴ The dPTIa- and dPTIb- thin films were fabricated by the spin-coating method (6000 rpm, 30 sec) using chloroform solution (4 g/L) and following thermal annealing (100 °C or 200 °C, 30 min). On the top of the organic thin film, gold films (80 nm) as drain and source electrodes were deposited through a shadow mask. For a typical device, the drain-source channel length (*L*) and width (*W*) are 40 µm and 1.5 mm, respectively. The device characteristics were measured at room temperature under ambient conditions with a Keithley 4200 semiconducting parameter analyzer. Field-effect mobility (μ) was calculated in the saturation regime using the following equation,

$$I_{\rm d} = C_i \,\mu \, (W/2L) \, (V_{\rm g} - V_{\rm th})^2$$

where C_i is the capacitance of the SiO₂ insulator, and V_g and V_{th} are the gate and threshold voltages, respectively.

Fabrication and characterization of OPV devices

Patterned ITO substrates (purchased from Atsugi Micro) were first pre-cleaned sequentially by

sonicating in a detergent bath, de-ionized water, acetone, and isopropanol at room temperature, and in boiled isopropanol each for 10 min, and then baked at 120 °C for 10 minutes in air. The substrates were then subjected to a UV/ozone treatment at rt for 20 min. ZnO layer was prepared by spin-coating (at 5000 rpm, 30 sec.) a precursor solution prepared from zinc acetate dehydrate (0.27 g) and ethanolamine (0.07 mL) in 2-methoxyethanol (2.5 mL). Then, the substrates were annealed at 170 °C on a hot plate in air. The glass/ITO/ZnO substrate was transferred into a nitrogen-filled glove box (KOREA KIYON, KK-011AS-EXTRA). Active layer (IDT-PTI and PBDB-T) solution (chlorobenzene, 16 mg/ml, donor/acceptor weight ratio is 1:1) was spin-coated at 1200 rpm for 40 s on the substrate. Then, MoO_x (7.5 nm) and Ag anode (100 nm) were deposited in vacuum to complete the solar cell devices. The active area of the cells was 0.16 cm². J-V characteristics of the cells were measured using a Keithley 2400 source-measure unit in nitrogen atmosphere under the 1 sun (AM1.5G) condition using a solar simulator (SAN-EI Electric, XES-40S1). The light intensity was calibrated with a reference PV cell (KONICA MINOLTA AK-100 certified at National Institute of Advanced Industrial Science and Technology, Japan). The EQE of each device was measured with monochromatic light (SM-250F, Bunkoh-Keiki). More than 8 different devices were fabricated to collect the photovoltaic properties. AFM images were obtained on a Nanotechnology, Inc. scanning probe microscope Nanocute system. X-ray studies were carried out using a Rigaku Ultima IV diffractometer with a CuK α source ($\lambda = 1.541$ Å).

3. Absorption and fluorescence spectra of NDI and PDI

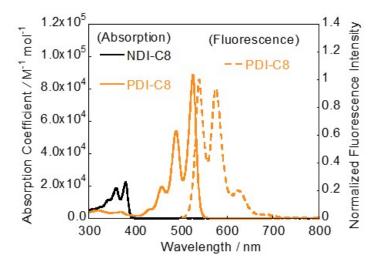


Figure S1. Absorption and fluorescence spectra of N,N'-dioctyl-NDI and N,N'-dioctyl-PDI in chloroform solution. N,N'-dioctyl-NDI did not show clear fluorescence.

4. Plausible mechanism of Na_2S -promoted thiophene annulation

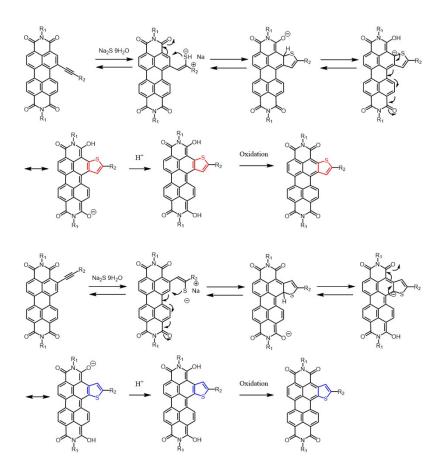


Figure S2. Plausible mechanism of Na_2S -promoted thiophene annulation on PDI-core from 2a and

2b.

5. Cyclic voltammograms

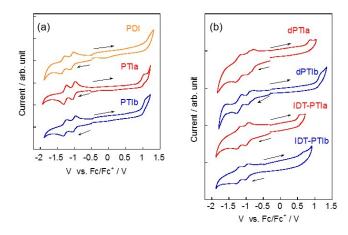


Figure S3. Cyclic voltammograms of PDI and PTIs (a) and dPTIs and IDT-PTIs(b)

6. Absorption spectra of dPTIs and IDT-PTIs in thin film

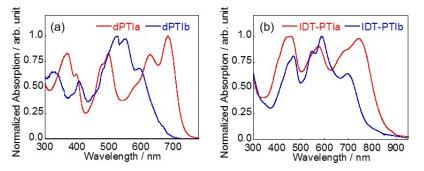


Figure S4. Absorption spectra of dPTIs (a) and IDT-PTIs (b) in thin film.

7. Logarithmic absorption spectra of dPTIs and IDT-PTIs

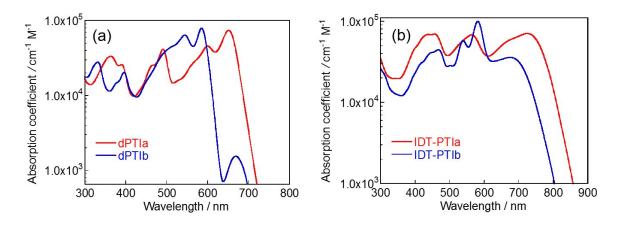


Figure S5. Logarithmic absorption spectra of dPTIs (a) and IDT-PTIs (b) in chloroform solution.

8. Dihedral angles of α, α' -linked thiophenes in the DFT-optimized molecular structures of dPTIs

and IDT-PTIs

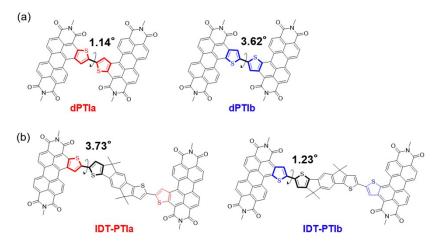


Figure S6. Dihedral angles of α, α' -linked thiophenes in the DFT-optimized molecular structures of dPTIs (a) and IDT-PTIs (b).

9. DFT-calculated HOMO and LUMO of PTIs

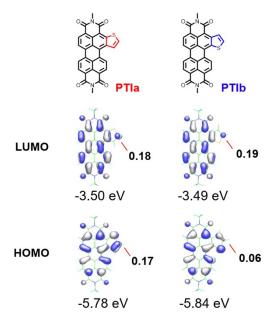


Figure S7. DFT-calculated HOMO and LUMO of PTIs and HOMO/LUMO coefficients at the α -carbon atoms of the fused thiophenes (B3LYP/6-31G*). The coefficients are given as absolute values.

10. AFM images

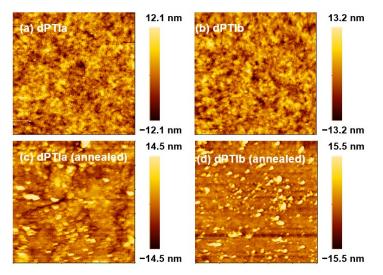


Figure S8. AFM images (5 μ m × 5 μ m) of dPTIa- and dPTIb-based OFETs with and without annealing (200 °C).

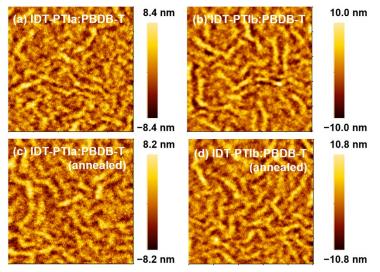
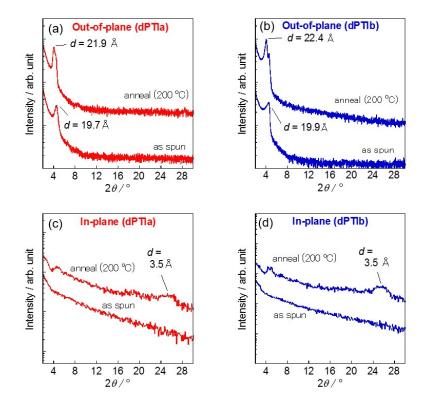


Figure S9. AFM images (5 μ m × 5 μ m) of IDT-PTIa:PBDB-T- and IDT-PTIb:PBDB-T-based OFETs with and without annealing (200 °C).



11. Out-of-plane and in-plane XRD patterns of thin-film of π -extended PTIs

Figure S10. Out-of-plane XRD patterns of thin-film of dPTIa and dPTIb (a,b) and in-plane patterns of thin-film of dPTIa and dPTIb (c,d).

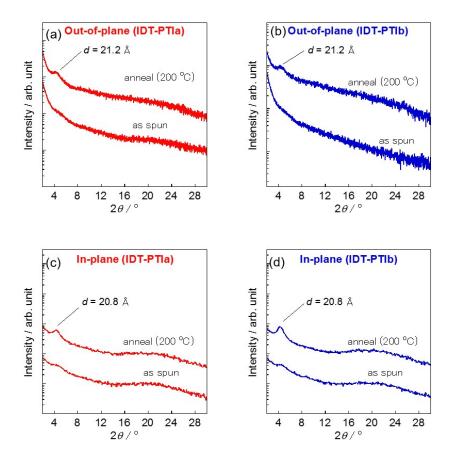


Figure S11. Out-of-plane XRD patterns of thin-film of IDT-PTIa and IDT-PTIb (a,b) and in-plane

patterns of thin-film of IDT-PTIa and IDT-PTIb (c,d).

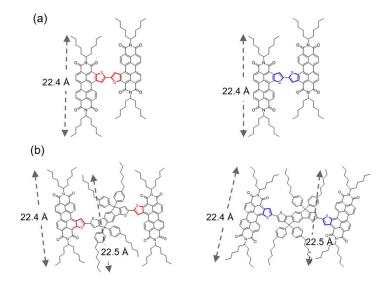
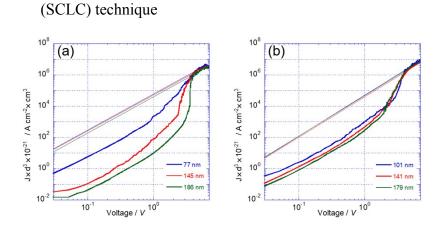


Figure S12. Molecular structures of dPTIs (a) and IDT-PTIs (b), and the distances between the edge of alkyl groups.



12. Evaluation of carrier mobilities of IDT-PTIs in the thin films by space-charge-limited current

Figure S13. Current density normalized by the cube of the film thickness (*d*) plotted against voltage for the electron-only devices with the thin films of (a) IDT-PTIa and (b) IDT-PTIb (annealed at 200 °C). The device structures of electron-only devices are ITO/ZnO/Active layer/Ca/Ag.

Table S1. Summary of the average slope of *J-V* curves for analyzing he Mott-Gurney law, and the averaged electron mobility in SCLC region.

	IDT-PTIa	IDT-PTIb	
Slope	2.29	2.57	
$\mu_{\rm e}$ / cm ² V ⁻¹ s ⁻¹	$4.8 imes10^{-4}$	$4.2 imes 10^{-4}$	

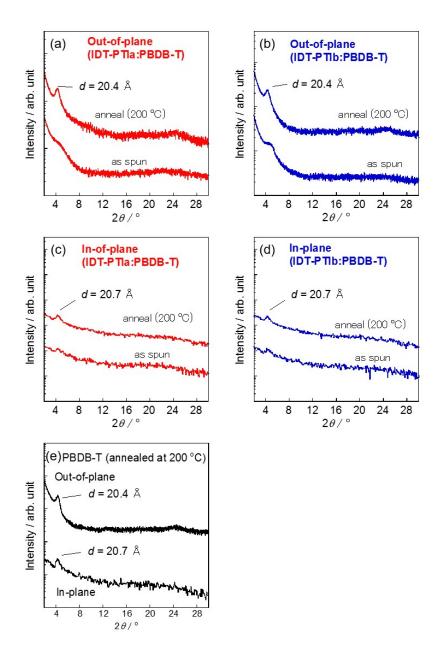
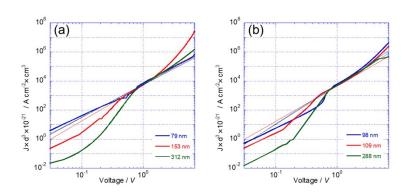


Figure S14. Out-of-plane XRD patterns of blend films of IDT-PTIa:PBDB-T and IDT-PTIb:PBDB-T and in-plane patterns of thin-film of IDT-PTIa:PBDB-T and IDT-PTIb:PBDB-T (c,d). XRD diffractions of PBDB-T (e).



14. Evaluation of carrier mobilities of blend films with IDT-PTIs:PBDB-T by SCLC technique

Figure S15. Current density normalized by the cube of the film thickness (*d*) plotted against voltage for the electron-only devices with the blend films of (a) IDT-PTIa:PBDB-T and (b) IDT-PTIb:PBDB-T. The device structures of electron-only devices are ITO/ZnO/Active layer/Ca/Ag.

Table S2. Summary of the average slope of J-V curves for analyzing he Mott-Gurney law, and the averaged electron mobility in SCLC region.

	IDT-PTIa:PBDB-T	IDT-PTIb:PBDB-T	
Slope	2.28	2.62	
$\mu_{\rm e} /{\rm cm}^2{ m V}^{-1}{ m s}^{-1}$	6.3 × 10 ⁻⁵	5.3 × 10 ⁻⁵	

15. Summarized device characteristics

Compound	Anneal / °C	operation	µ _{FET} / cm ² V ¹ s ^{−1}	μ _{FET} ^{max} / cm ² V ⁻¹ s ⁻¹	I on /I off	V _{th} / V
dPTIa		n-channel	0.0092±0.0012	0.0104	~1.5×10 ⁴	12.3±2.8
	100	p-channel	0.0004±0.0001	0.0005	~1.9×10 ²	-44.2±2.9
	100	n-channel	0.0127±0.0041	0.0168	~1.5×10 ³	10.1±5.2
	100	p-channel	0.0031±0.0009	0.0040	~3.4×10 ²	-34.2±12.2
	200	n-channel	0.0882±0.0040	0.0922	~5.0×10 ²	13.3±3.3
		p-channel	0.0198±0.0034	0.0232	~3.7×10 ²	-22.5±5.4
dPTIb		n-channel	0.0070±0.0014	0.0084	~1.8×10 ⁶	1.6±2.3
	_	p-channel	-	-	-	_
	400	n-channel	0.0167±0.0023	0.0190	~9.2×10 ⁶	9.1±4.3
	100	p-channel	7	-	100	
	200	n-channel	0.0378±0.0053	0.0431	~7.8×10 ⁵	11.8±6.3
	200	p-channel	-	_	-	_

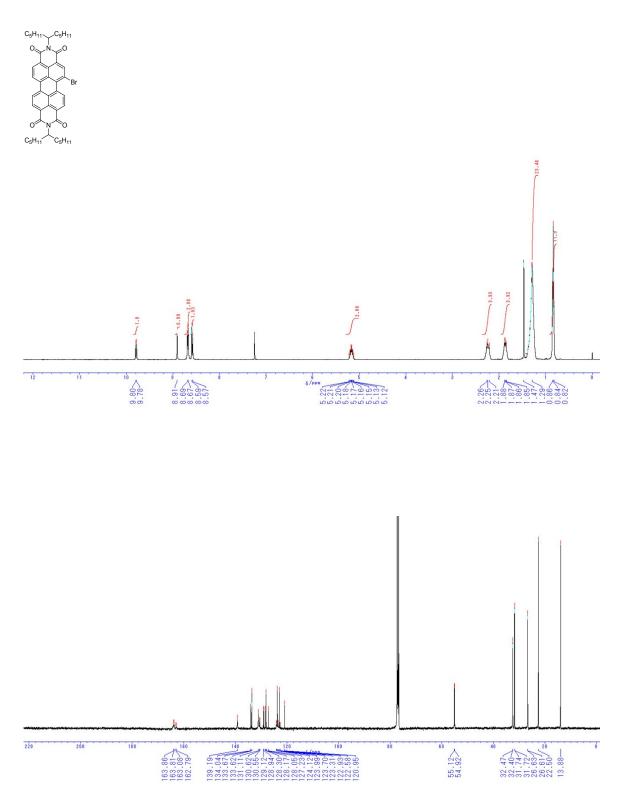
Table S3. Summarized transistor characteristics of dPTI-based OFETs

Table S4. Summarized properties of IDT-PTIa:PBDB-T- and IDT-PTIb:PBDB-T-based OPVs

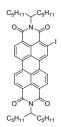
Active Materials	Anneal	J _{SC} / mAcm ⁻²	V _{oc} /V	FF	PCE/%	PCE ^{max} / %
IDT-PTIa:PBDB-T	-	8.60±0.42	0.83±0.01	0.49±0.02	3.2±0.6	3.8
	200	12.32±0.46	0.78±0.01	0.48±0.03	4.7±0.4	5.1
IDT-PTIb:PBDB-T	-	7.57±0.33	0.86±0.01	0.50±0.01	3.3±0.2	3.5
	200	10.06±0.45	0.82±0.00	0.56±0.02	4.7±0.2	4.9

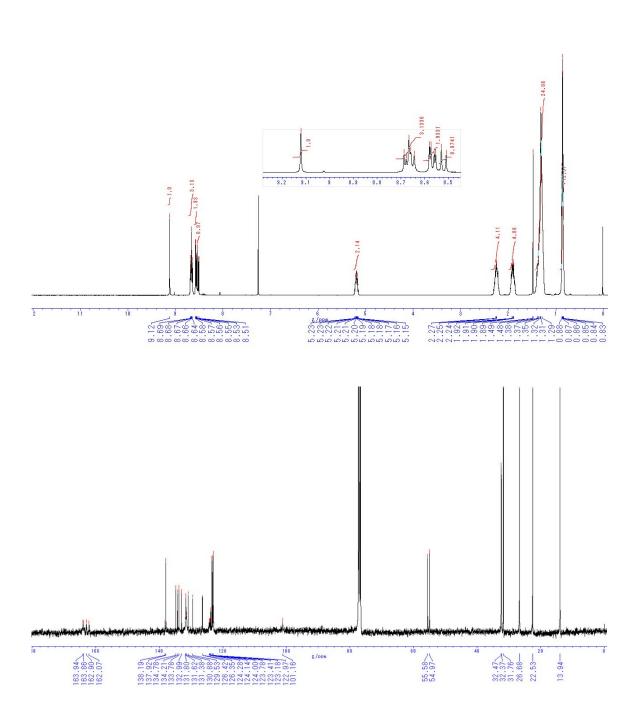
16. NMR charts

N,*N*'-bis(1-penthylhexyl)-1-bromoperylene-3,4,9,10-tetracarboxydiimide (1a)



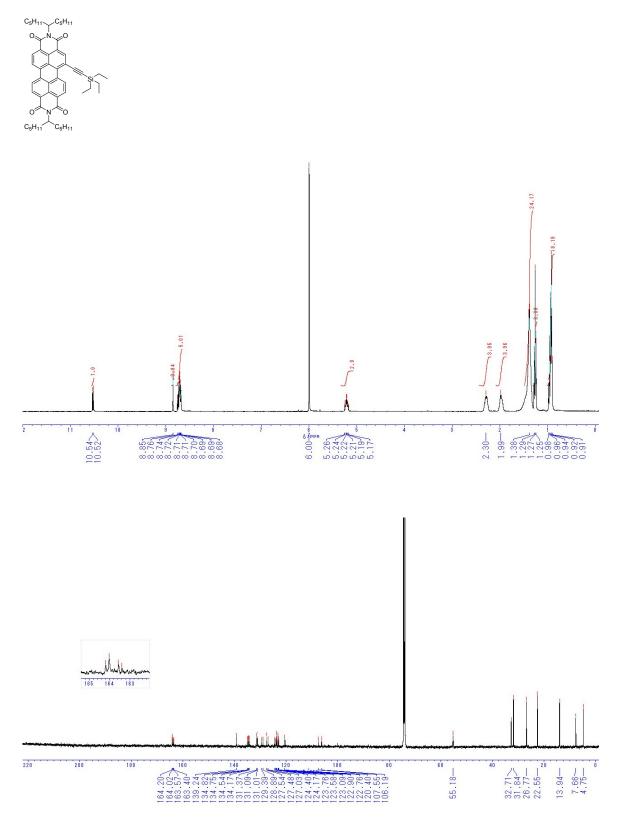
N,N'-Bis(1-pentylhexyl)-2-iodoperylene-3,4,9,10-tetracarboxydiimide (1b)



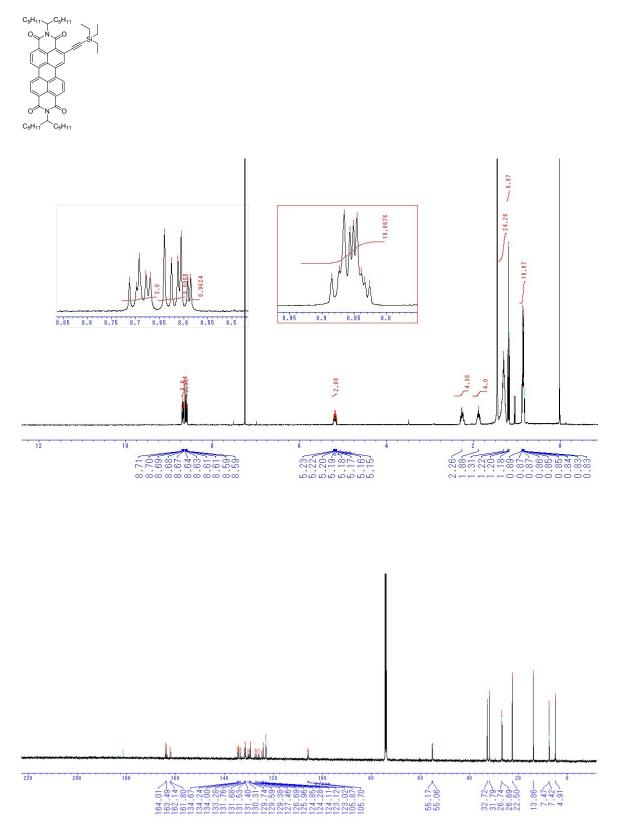


S20

N,N'-Bis(1-pentylhexyl)-1-(triethylsilylethynyl)-perylene-3,4,9,10-tetracarboxydiimide (2a)

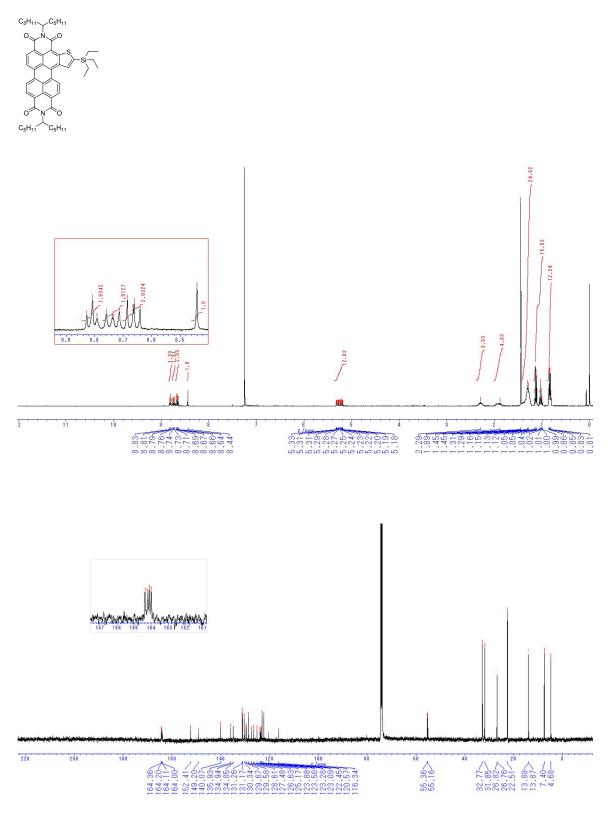


N,N'-Bis(1-pentylhexyl)-2-(triethylsilylethynyl)-perylene-3,4,9,10-tetracarboxydiimide (2b)



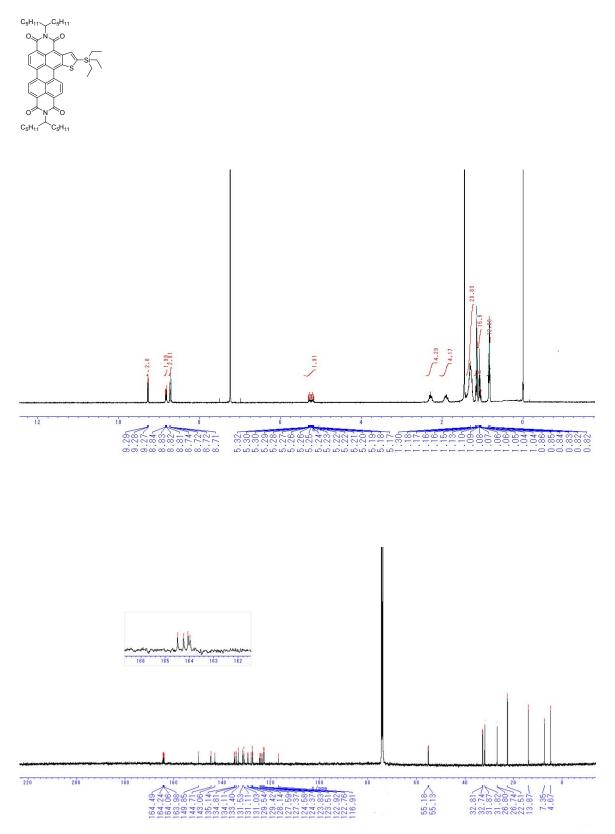
N,N'-Bis(1-pentylhexyl)-2-(triethylsilyl)-peryleno[2,1-b]thiophene-6,7,12,13-

tetracarboxydiimide (TES-PTIa)

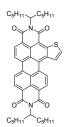


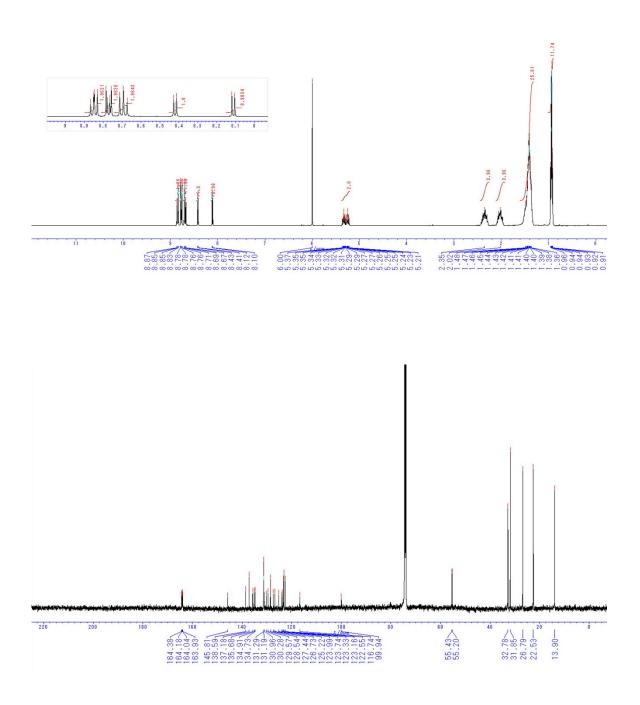
N,N'-Bis(1-pentylhexyl)-2-(triethylsilyl)-peryleno[1,2-b]thiophene-4,5,10,11-

tetracarboxydiimide (TES-PTIb)

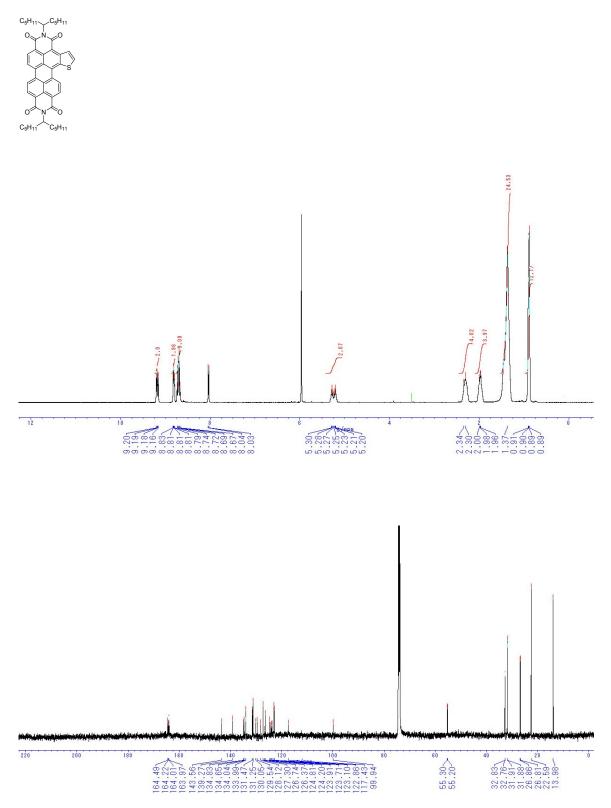


N,*N*'-Bis(1-pentylhexyl)-peryleno[2,1-*b*]thiophene-6,7,12,13-tetracarboxydiimide (PTIa)



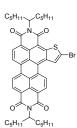


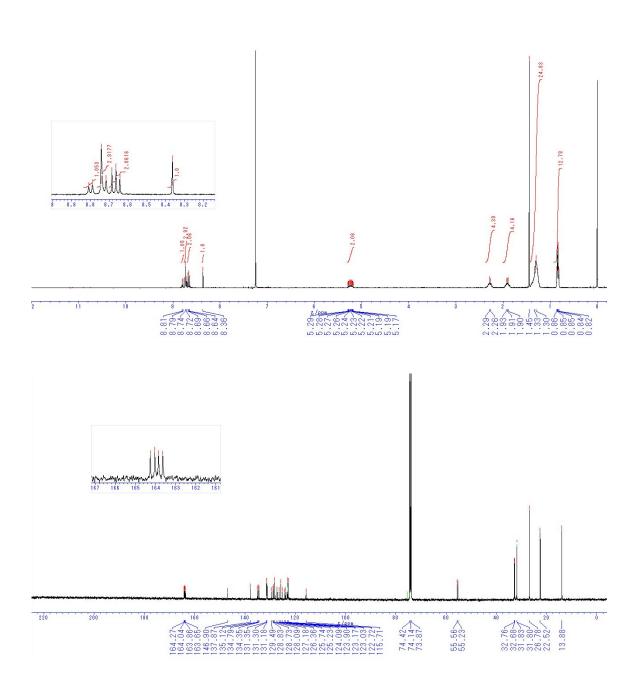
N,*N*'-Bis(1-pentylhexyl)-peryleno[1,2-*b*]thiophene-4,5,10,11-tetracarboxydiimide (PTIb)



N,N'-Bis(1-pentylhexyl)-2-bromoperyleno[2,1-b]thiophene-6,7,12,13-tetracarboxydiimide (Br-

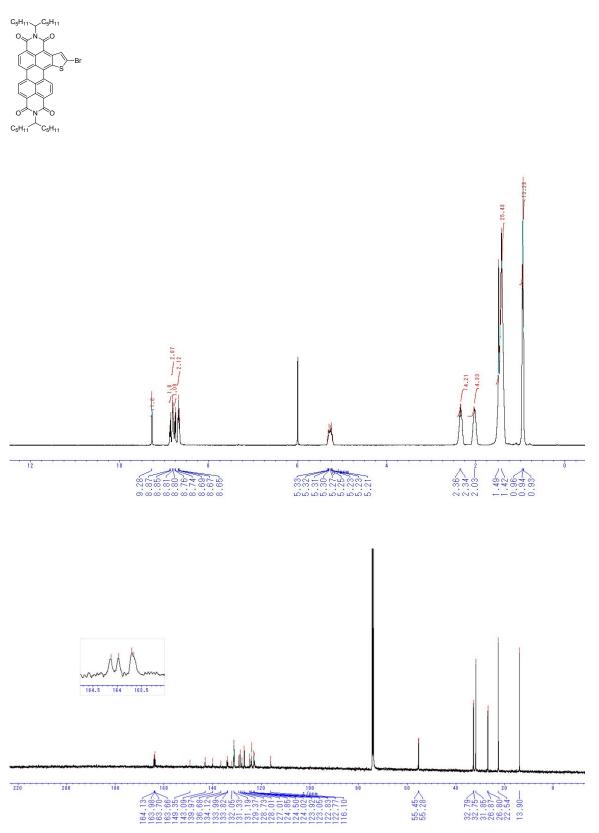






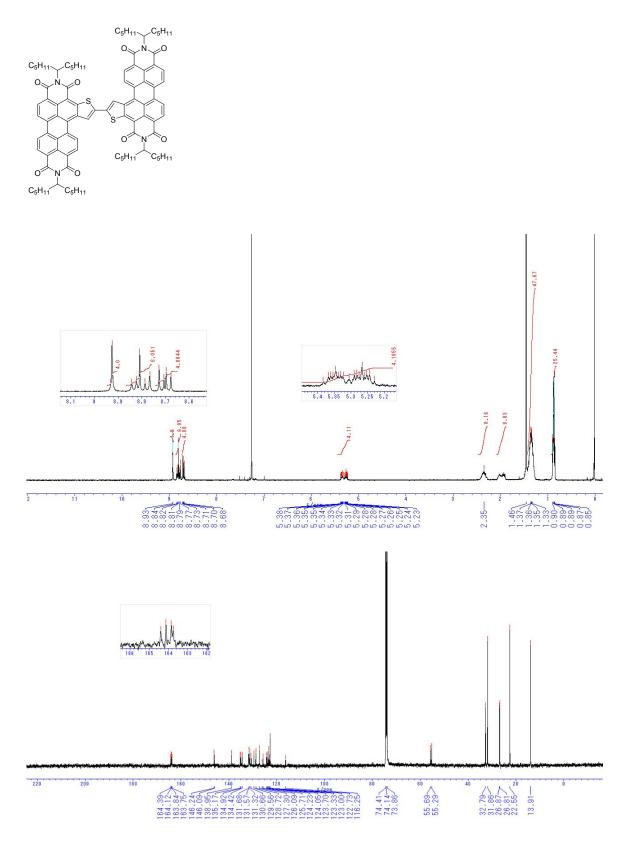
N,N'-Bis(1-pentylhexyl)-2-bromoperyleno[1,2-b]thiophene-4,5,10,11-tetracarboxydiimide (Br-





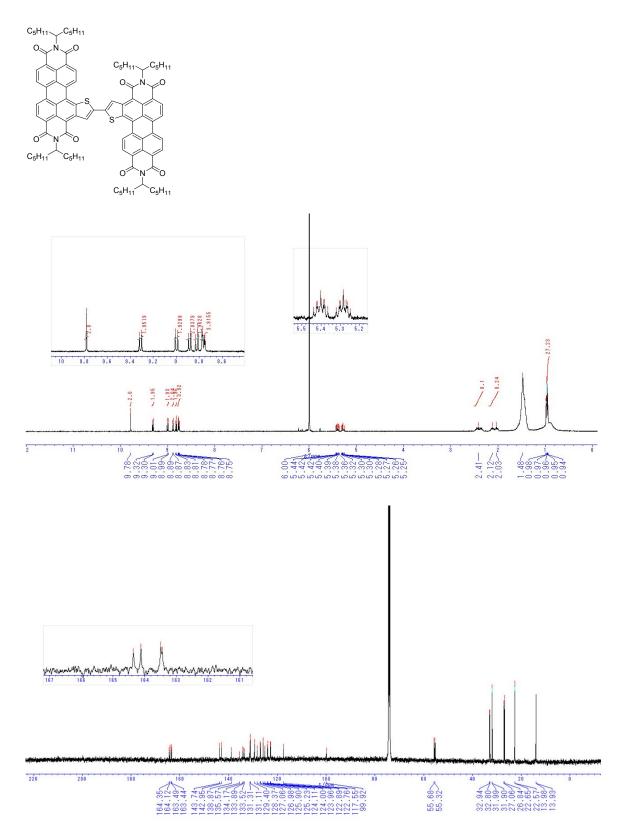
[2,2']Bi[peryleno[2,1-b]thienyl]-N,N',N'',N'''-tetrakis(1-pentylhexyl)-6,6',7,7',12,12',13,13'-

tetraimide (dPTIa)



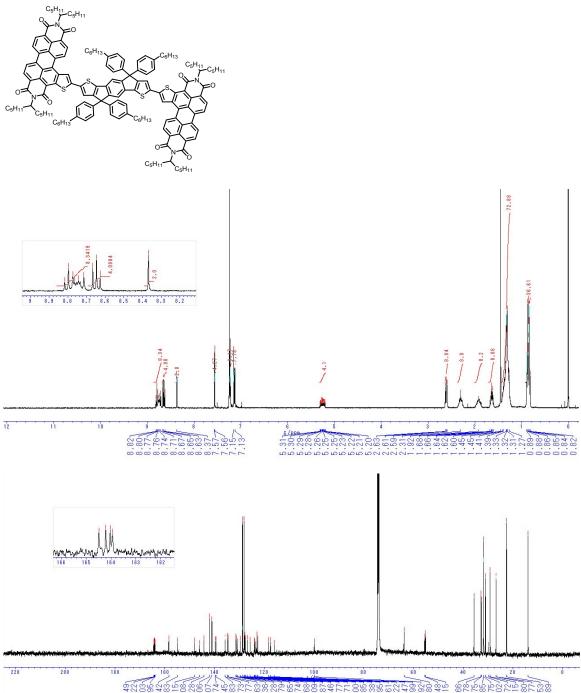
[2,2']Bi[peryleno[1,2-b]thienyl]-N,N',N'',N'''-tetrakis(1-pentylhexyl)-4,4',5,5',10,10',11,11'-

tetraimide (dPTIb)



N,N',N'',N'''-Tetrakis(1-pentylhexyl)-2,7-bis(peryleno[2,1-b]thiophen-2-yl)-4,4,9,9-tetrakis(4-

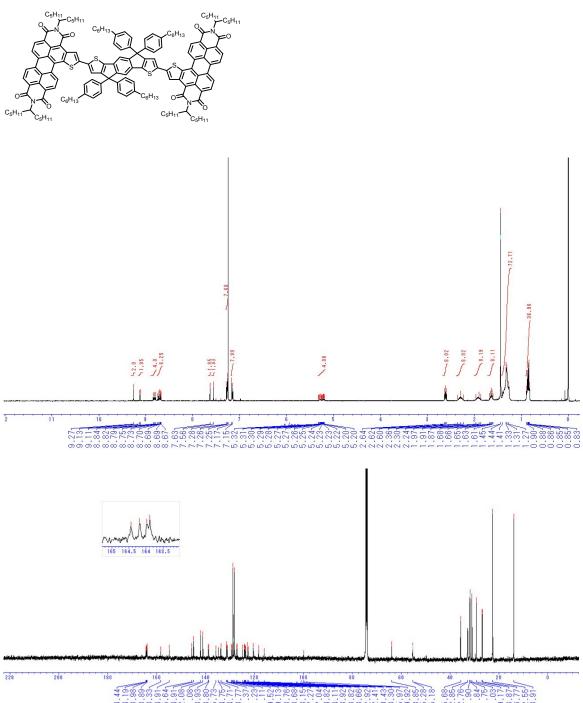
hexylphenyl)-s-indaceno[1,2-b:5,6-b']dithiophene-6',6'',7',7'',12',12'',13',13''-



octacarboxytetraimide (IDT-PTIa)

164 4.49 164 4.49
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164 4. N,N',N'',N'''-Tetrakis(1-pentylhexyl)-2,7-bis(peryleno[1,2-b]thiophen-2-yl)-4,4,9,9-tetrakis(4-

hexylphenyl)-s-indaceno[1,2-b:5,6-b']dithiophene-4',4'',5',5'',10',10'',11',11''-



octacarboxytetraimide (IDT-PTIb)

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